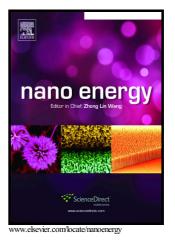
## Author's Accepted Manuscript

Electron Blocking Layer-based Interfacial Design for Highly-enhanced Triboelectric Nanogenerators

Hyun-Woo Park, Nghia Dinh Huynh, Wook Kim, Choongyeop Lee, Youngsuk Nam, Sangmin Lee, Kwun-Bum Chung, Dukhyun Choi



 PII:
 S2211-2855(18)30338-0

 DOI:
 https://doi.org/10.1016/j.nanoen.2018.05.024

 Reference:
 NANOEN2732

To appear in: Nano Energy

Received date: 10 April 2018 Revised date: 10 May 2018 Accepted date: 10 May 2018

Cite this article as: Hyun-Woo Park, Nghia Dinh Huynh, Wook Kim, Choongyeop Lee, Youngsuk Nam, Sangmin Lee, Kwun-Bum Chung and Dukhyun Choi, Electron Blocking Layer-based Interfacial Design for Highlyenhanced Triboelectric Nanogenerators, *Nano Energy*, https://doi.org/10.1016/j.nanoen.2018.05.024

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting galley proof before it is published in its final citable form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.

## Electron Blocking Layer-based Interfacial Design for Highly-enhanced Triboelectric Nanogenerators

Hyun-Woo Park<sup>a1</sup>, Nghia Dinh Huynh<sup>a,1</sup>, Wook Kim<sup>a</sup>, Choongyeop Lee<sup>a</sup>, Youngsuk Nam<sup>a</sup>, Sangmin Lee<sup>c</sup>, Kwun-Bum Chung<sup>b,\*</sup> and Dukhyun Choi<sup>a,\*</sup>

<sup>a</sup>Department of Mechanical Engineering, Kyung Hee University, 1732 Deogyeong-daero, Giheung-gu, Yongin-Si, Gyeonggi-do 446-701, South Korea.

<sup>b</sup>Department of Physics and Semiconductor Science, Dongguk University, Seoul, 100-715, Korea

mar

<sup>c</sup>School of Mechanical Engineering, Chung-Ang University, Seoul, 06974, Korea

oted

dchoi@khu.ac.kr (D. Choi)

kbchung@dongguk.edu (K.-B. Chung)

\*Corresponding author.

## ABSTRACT

The key to enhance the output power from triboelectric nanogenerators (TENGs) is to control the surface charge density of tribo-materials. In this study, we introduce an electron blocking layer (EBL) between a negative tribo-material and an electrode to dramatically enhance the output power of TENGs. For the first time, we suggest that the tribo-potential can be significantly reduced by the presence of interfacial electrons; electrostatically induced positive charges at the interface beneath a negative tribo-material can be screened out by the electrons, thereby

<sup>&</sup>lt;sup>1</sup>These authors are Equally contributed.

Download English Version:

## https://daneshyari.com/en/article/7952387

Download Persian Version:

https://daneshyari.com/article/7952387

Daneshyari.com